This listing of claims will replace all prior versions, and listings, of claims in the application:

## **Listing of Claims**

- 1-16. cancelled
- 17. (currently amended) A micro-electro-mechanical system (MEMS) package for hermetically sealing a MEMS device, comprising:

the MEMS package having a fill port, wherein the fill port is a through hole capable of having at least one medium inserted through the fill port.

at least one <u>low temperature curing</u> sealant placed within the fill port wherein the at least one <u>low temperature curing</u> sealant substantially fills the fill port; and

a metal cap placed over the at least one <u>low temperature curing</u> sealant in a specific pattern wherein the metal cap substantially hermetically seals the fill port.

- 18. (original) A MEMS package as in claim 17, further comprising a MEMS device placed within the MEMS package.
- 19. (original) A MEMS package as in claim 18, further comprising a bond ring surrounding the MEMS device.
- 20. (original) A MEMS package as in claim 19, wherein the fill port is located in a break in the bond ring.

- 21. (original) A MEMS package as in claim 17, further comprising a lid disposed above the bond ring.
- 22. (original) A MEMS package as in claim 21, wherein the fill port is a through-hole located in the lid.
- 23. (original) A MEMS package as in claim 21, wherein the lid is selected from the group of materials consisting of glass and silicon.
- 24. (currently amended) A MEMS package as in claim 17, wherein the one or moreat least one low temperature curing sealants placed within the fill hole-port is an organic sealant selected from the group consisting of thermal-set epoxy, UV curable epoxy, two-part epoxy, silicone, and spin-on polyamides.
- 25. (currently amended) A MEMS package as in claim 17, wherein the at least one low temperature curing sealant is an inorganic sealant.
- 26. (original) A MEMS package as in claim 17, wherein the at least one medium is a gas selected from the group of media consisting of air, nitrogen, oxygen, and argon.

- 27. (original) A MEMS package as in claim 17, wherein the at least one medium is a liquid selected from the group of liquid media consisting of a low vapor pressure oil, a lubricant, and a hydrophobic fluid.
- 28. (original) A MEMS package as in claim 27, wherein the liquid refractive index is similar to a lid refractive index.
- 29. (original) A MEMS package as in claim 27, wherein the liquid has a coefficient of thermal expansion similar to that of the MEMS device.
- 30. (original) A MEMS package as in claim 17, wherein the at least one medium is a solid selected from the group of solid media consisting of sol gel.
- 31. (currently amended) A MEMS package as in claim 17, wherein the at least one low temperature curing sealant is cured using a low temperature curing process and the MEMS package is cleaned, wherein the low temperature curing process occurs at a temperature less than 100 degrees Celsius.

- 32. (currently amended) A MEMS package as in claim 17, wherein the metal cap is formed over the at least one <u>low temperature curing</u> sealant using a low temperature process selected from the group consisting of electron beam deposition and physical vapor deposition.
- 33. (original) A MEMS package as in claim 17, comprising a metal cap made from one or more types of metal, said one or more types of metal selected from the group consisting of gold, titanium, silver, aluminum, chromium, and tantalum.
- 34. (currently amended) A micro-electro-mechanical system (MEMS) package for hermetically sealing a MEMS device, comprising:

a means for filling a MEMS package through a fill port with at least one medium; a means for plugging the fill port in the MEMS package with at least one <u>low</u> temperature curing sealant; and

a means for hermetically sealing a metal cap in a specific pattern over the at least one low temperature curing sealant.